Electrical characteristics of lithium surfaces exposed to a plasma

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MOTIVATION





Lithium coating of TJ-II (Heliac type stellerator)

•The coating technique is based on vacuum vaporisation of solid lithium (4 gr each conditioning cycle) from effusive sources at temperatures of 500-600°C

•The presence of an underlying boron coating deposited previous to the lithiation, crucially affected the lifetime of the Li layer.





Effect of lithium in the TJ-II operation

•Substantial improvement of the main plasma parameters, particle and energy confinement

•Control of the density ramp in NBI plasmas (not achieved with boronized walls).

•Extension of the TJ-II operational window.

•Achievement of H-mode

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Experiments in TJ-II

The sputtering and desorption characteristics of H and He plasmas on a Li surface

Hydrogen plasma



Sputtering yield < TRIM calculation Eth > TRIM calculation

Helium plasmas



Eth Sputtering Li ~ Eth H desorption Same energy dependence

Both species, Li and H could obey to the same release mechanism

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Experiments in laboratory are necessary:

-Check of the Li sputtering in presence of H

-Study of factors that affects the process: role of B

And

To find new positive effects of lithium surfaces other than low recycling

Tritium control in fusion reactors calls for a high recycling scenario

In order to figure out the influence of the surface condition in the sputtering, three surface coatings had been studied in the laboratory experiments:

- -Li coating
- -Li and H coating
- -Li and B coating

SETUP





Li + H COATING





2. Cleaning of the chamber: \longrightarrow Monitoring of H α signal

-He plasma

-High potentials in the bar

Li + B COATING





Ortocarborane sublimation —→ Monitoring of the pressure Break of the molecule: He plasma







Laboratorio

Nacional

Fusión

Li COATING



Sputtering Yield





Coating	Li	Li + H	Li + B	Fit (Bohdanskv)
Eth (eV)	20	30	45	$Y = QSn(E) \left(1 - \frac{E_{th}}{E}\right)^2 \left(1 - \left(\frac{E_{th}}{E}\right)^{2/3}\right)$
Sputtering /ield (max)	92	56	46	

LI COATING



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Li and Li – H COATING

GOBIERNO DE ESPAÑA E INNOVACIÓN V Tecnológias



Secondary electron emission ? Additional ion current?

This phenomenon appears to be related to the sputtering:

-starts at energies near of Eth

-the values are higher for conditions with higher sputtering yield No conventional secondary emission of electrons:

•Li electron secondary emission coefficient= 0,5 (upper limit for ion induced electron emission)

•Here maximum ~ 1,5

•Conventional secondary_electron emission peaks at higher energies







•Anomalous negative current is detected at slightly negative bias on lithium and lithium-hydrogen surface

•Not detected under boronized-Li conditions

•Energy dependence showing threshold and yield characteristics of sputtering

•Could be associated to plasma ionization of sputtered (excited) neutrals